

# EE 330

## Lecture 36

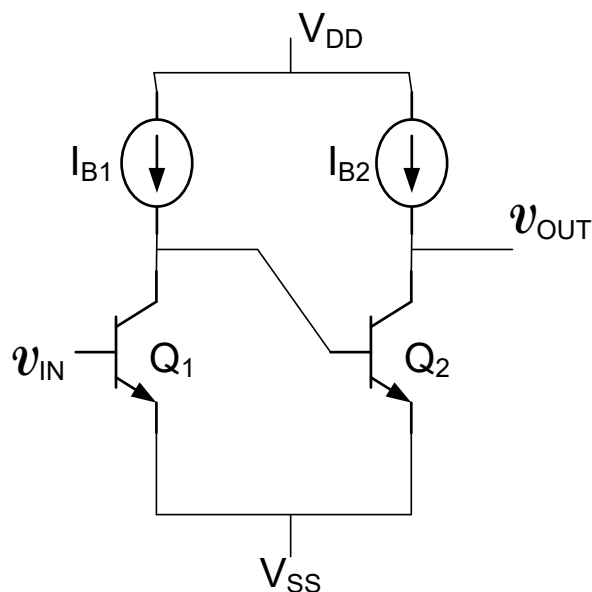
High Frequency Operation of Amplifiers  
Digital Circuit Design

- Basic Logic Gates
- Properties of Logic Families

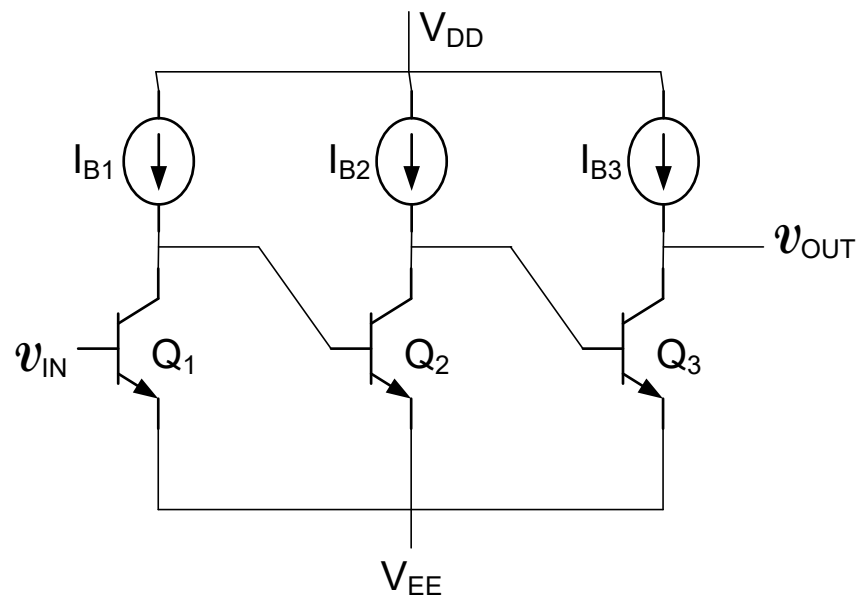
# Fall 2023 Exam Schedule

Exam 1	Friday Sept 22	
Exam 2	Friday Oct 20	
Exam 3	Friday Nov. 17	
Final	Monday Dec 11	12:00 – 2:00 p.m.

# Cascade Configurations



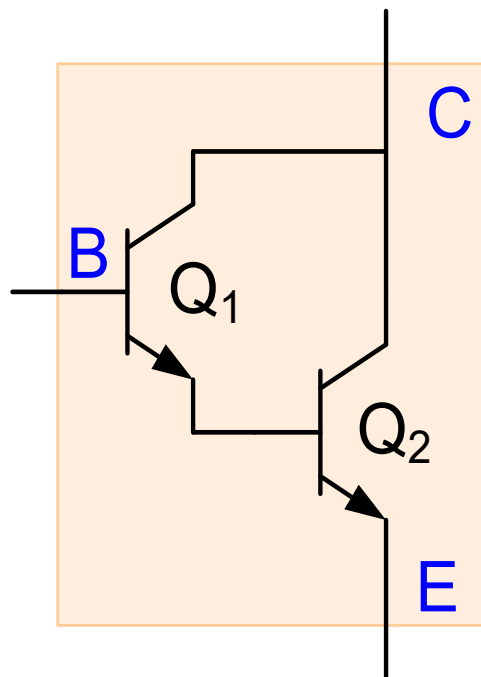
**Two-stage CE Cascade**



**Three-stage CE Cascade**

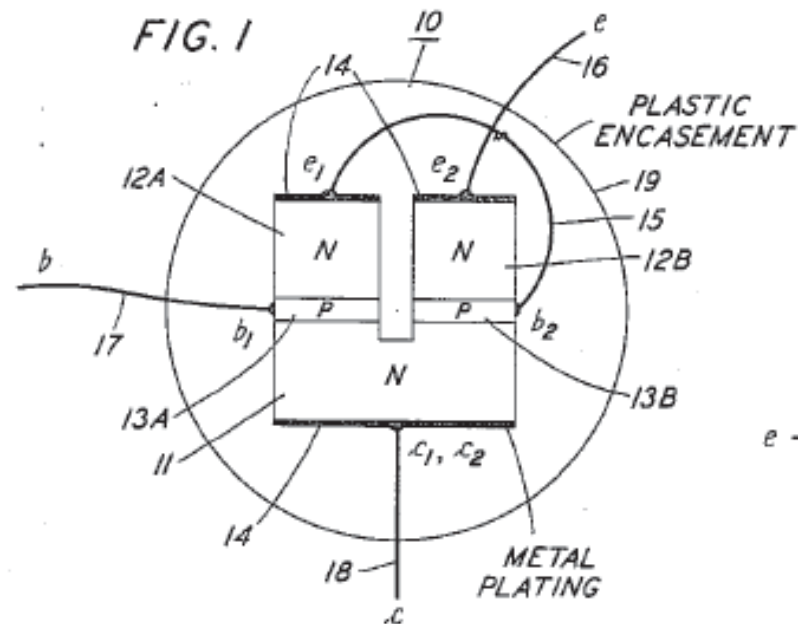
- Large gains can be obtained by cascading
- Gains are multiplicative (when loading is included)
- Large gains used to build “Op Amps” and feedback used to control gain value
- Some attention is needed for biasing but it is manageable
- Minor variant of the two-stage cascade often used to build Op Amps
- Compensation of two-stage cascade needed if feedback is applied to maintain stability
- For many years three or more stages were seldom cascaded because of challenges in compensation to maintain stability though recently some industrial adoptions

# Other Basic Configurations



**Darlington Configuration**

- Current gain is approximately  $\beta^2$
- Two diode drop between  $B_{\text{eff}}$  and  $E_{\text{eff}}$

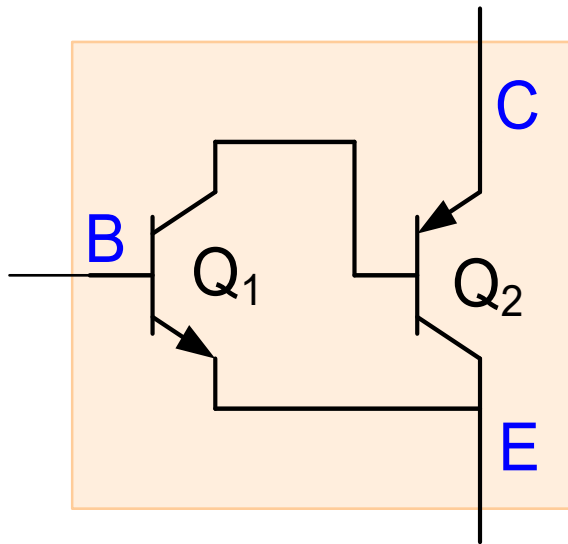


S. DARLINGTON  
SEMICONDUCTOR SIGNAL TRANSLATING DEVICE

2,663,806

Filed May 9, 1952

# Other Basic Configurations



Sziklai Pair

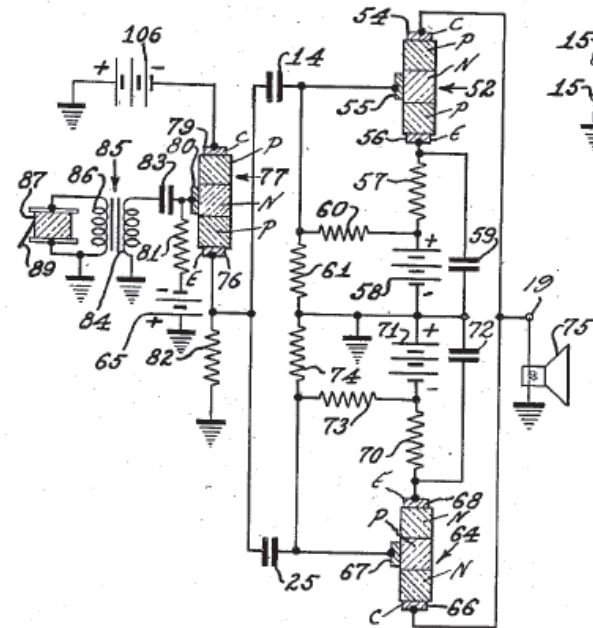


FIG. 3.

May 7, 1957

G. C. SZIKLAI

2,791,644

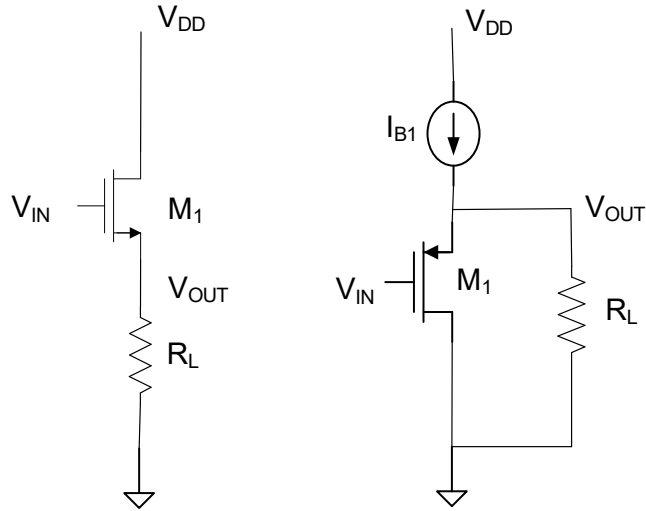
PUSH-PULL AMPLIFIER WITH COMPLEMENTARY TYPE TRANSISTORS

Filed Nov. 7, 1952

- Gain similar to that of Darlington Pair
- Current gain is approximately  $\beta_n \beta_p$
- Current gain will not be as large when  $\beta_p < \beta_n$
- Only one diode drop between  $B_{\text{eff}}$  and  $E_{\text{eff}}$

# Other Basic Configurations

## Buffer



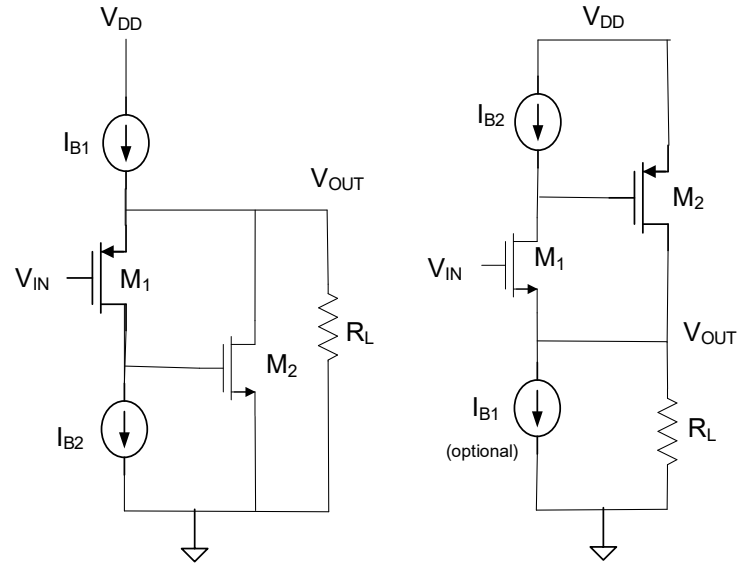
Ideally  $V_{OUT} = V_{IN}$

Assume load terminated on gnd

Current through  $M_1$  changes with  $V_{IN}$

Voltage shift varies with  $V_{IN}$  in buffer

## Super Buffer



Ideally  $V_{OUT} = V_{IN}$

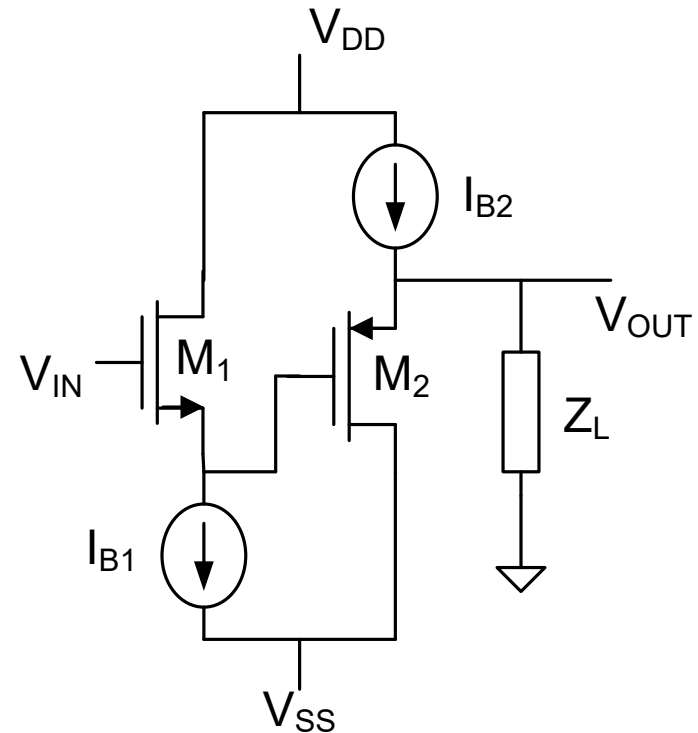
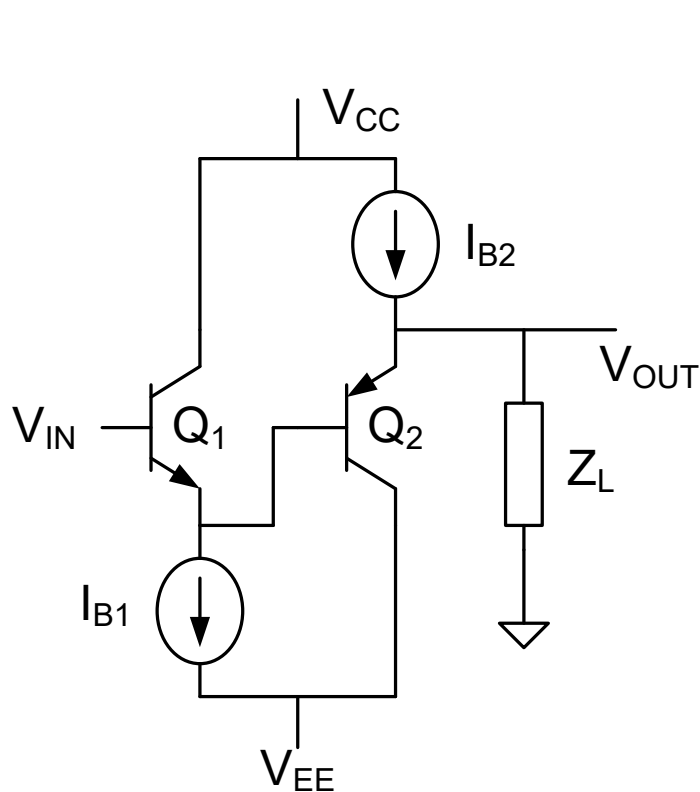
Assume load terminated on gnd

Current through shift transistor is constant for Super Buffer as  $V_{IN}$  changes so voltage shift does not change with  $V_{IN}$

Same nominal voltage shift as buffer

# Other Basic Configurations

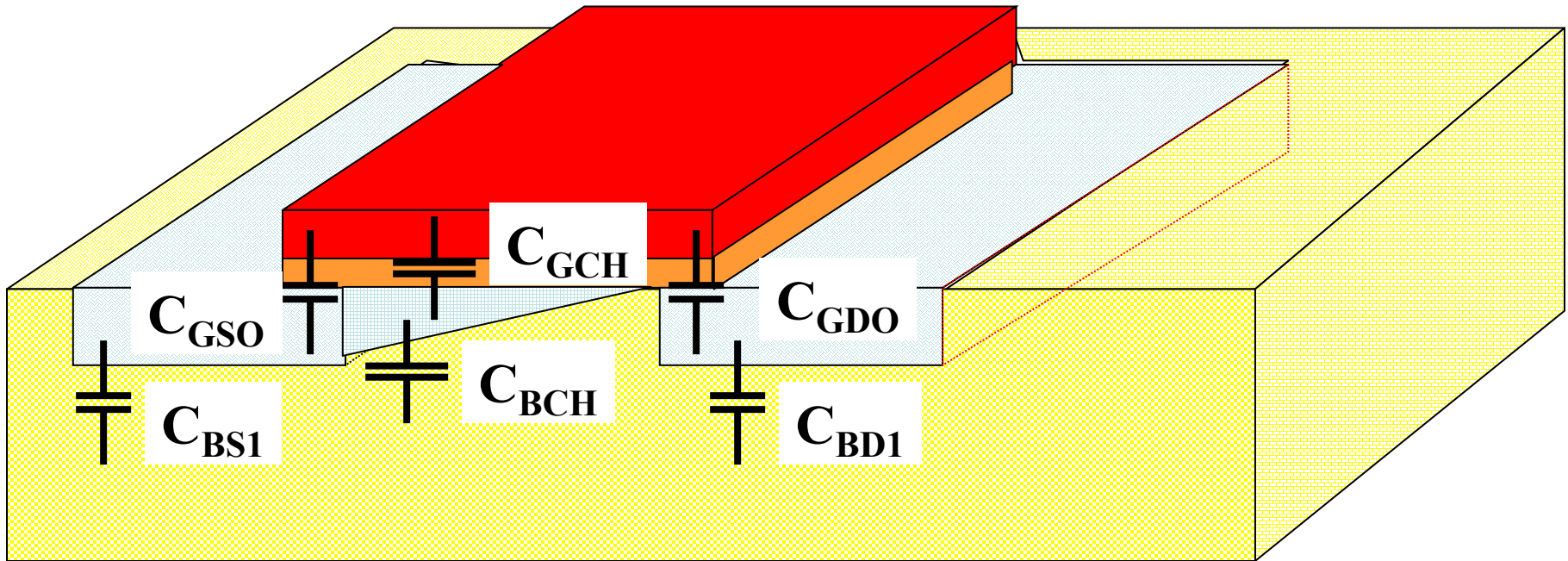
## Low offset buffers



- **Actually a CC-CC or a CD-CD cascade**
- **Significant drop in offset between input and output**
- **Biasing with DC current sources**
- **Can Add Super Buffer to Output**

# Parasitic Capacitors in MOSFET

Operation Region Dependent and Fixed --Saturation



Overlap Capacitors:  $C_{GDO}$ ,  $C_{GSO}$

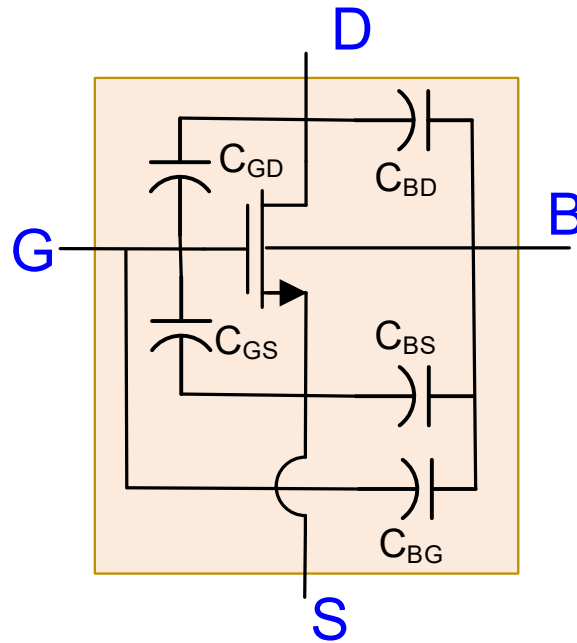
Junction Capacitors:  $C_{BS1}$ ,  $C_{BD1}$

**Saturation Capacitors:  $C_{GCH}$ ,  $C_{BCH}$**

- $2/3 C_{OX}WL$  is often attributed to  $C_{GCH}$  to account for LD and saturation
- This approximation is reasonable for minimum-length devices but not so good for longer devices



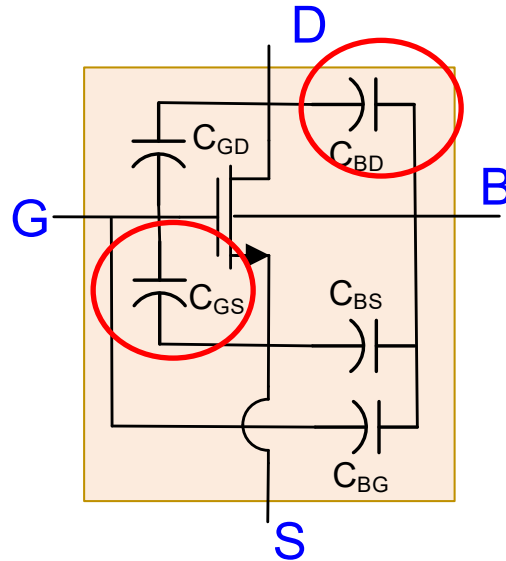
# Parasitic Capacitance Summary



	<b>Cutoff</b>	<b>Ohmic</b>	<b>Saturation</b>
$C_{GS}$	$C_{ox}W L_D$	$0.5C_{ox}WL$	$C_{ox}W L_D + (2/3)C_{ox}WL$
$C_{GD}$	$C_{ox}W L_D$	$0.5C_{ox}WL$	$C_{ox}W L_D$
$C_{BG}$	$C_{ox}WL$ (or less)	0	0
$C_{BS}$	$C_{BOT}A_S + C_{SW}P_S$	$C_{BOT}A_S + C_{SW}P_S + 0.5WLC_{BOTCH}$	$C_{BOT}A_S + C_{SW}P_S + (2/3)WLC_{BOTCH}$
$C_{BD}$	$C_{BOT}A_D + C_{SW}P_D$	$C_{BOT}A_D + C_{SW}P_D + 0.5WLC_{BOTCH}$	$C_{BOT}A_D + C_{SW}P_D$

Observe there is no  $C_{DS}$  in this model because does not physically exist

# Parasitic Capacitance Implications



The parasitic capacitances inherently introduce an upper limit on how fast either digital circuits or analog circuits can operate in a given process

Two parameters,  $f_{MAX}$  and  $f_T$ , (not defined yet) are two metrics that are used to specify the fundamental speed limit in a semiconductor process

The dominant parasitic capacitances for most circuits are  $C_{GS}$  and  $C_{BD}$

# $f_T$ and $f_{MAX}$ for a semiconductor process

$f_T$  is defined to be the frequency where the short-circuit current gain of a transistor drops to unity

$f_{MAX}$  is defined to be the frequency where the power gain of the transistor drops to unity (related to the maximum frequency of oscillation in a process)

$$f_T \approx \frac{3}{4\pi} \frac{\mu V_{EB}}{L_{min}^2} = \frac{3}{16\pi} \frac{\mu |V_{DD} - V_{TH}|}{(\lambda - LD)^2}$$

$f_T$  strongly dependent on  $V_{EB}$

for the ON 0.5u process

$$\mu_n C_{OX} = 100 \mu A/V^2$$

$$C_{OX} = 2.4 \text{ fF}/\mu^2$$

$$\lambda = 0.2 \mu$$

$$LD = .05 \mu$$

$$V_{THn} = 0.8 \text{ V}$$

$$\mu_n = 4E10 \text{ A}\mu^2\text{F}^{-1}\text{V}^{-2}$$

$$\mu_n = 400 \text{ cm}^2\text{AF}^{-1}\text{V}^{-2}$$

At  $V_{EB} = 1 \text{ V}$ ,  $f_T = 25 \text{ GHz}$

Note: As feature sizes shrink with process nodes,  $V_{EB-MAX}$  will typically drop linearly but  $L_{min}$  will drop quadratically thus  $f_T$  gets much larger in small feature processes

# $f_T$ and $f_{MAX}$ for a semiconductor process

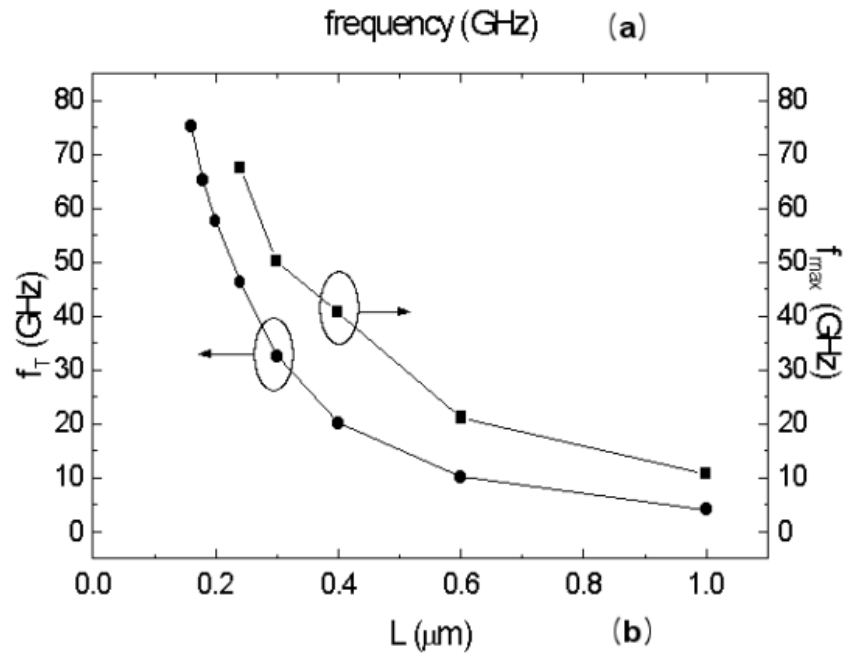
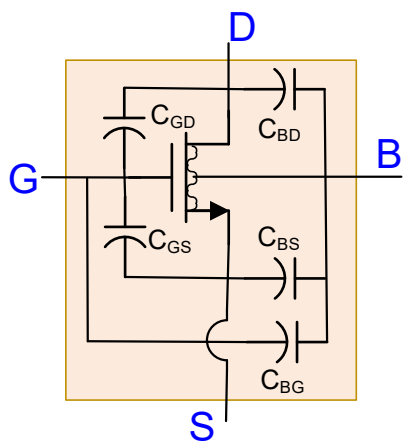
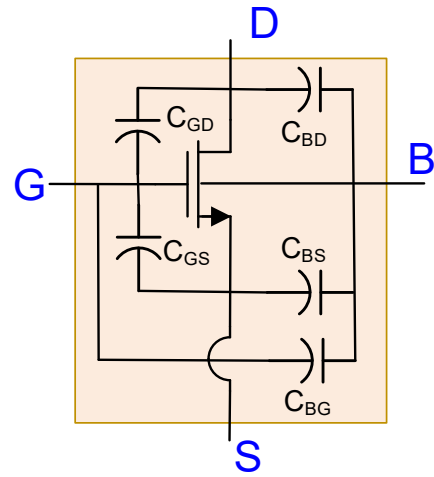


Fig. 7. (a) Maximum stable gain (MSG) and maximum available gain (MAG) for different channel lengths and (b) the cutoff frequency ( $f_T$ ) and maximum oscillation frequency ( $f_{max}$ ) as functions of the channel length.

For 0.18 $\mu$  process,  $V_D=2V$ ,  $V_G=1.2V$

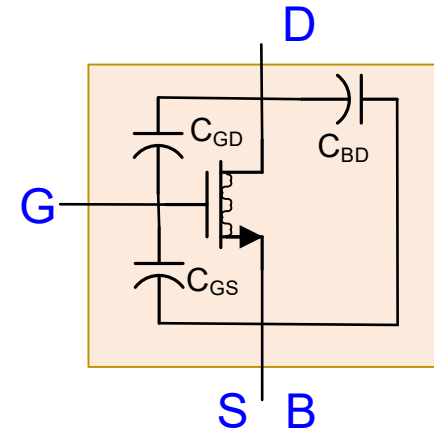
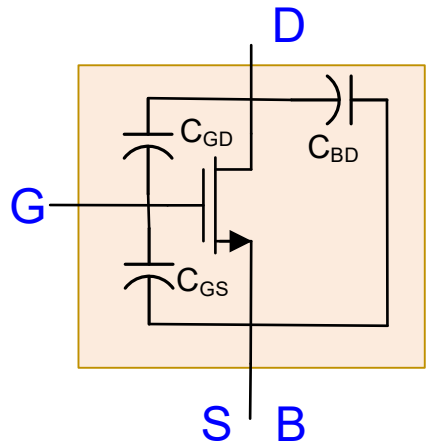
# Parasitic Capacitance Summary



High Frequency Large Signal Model

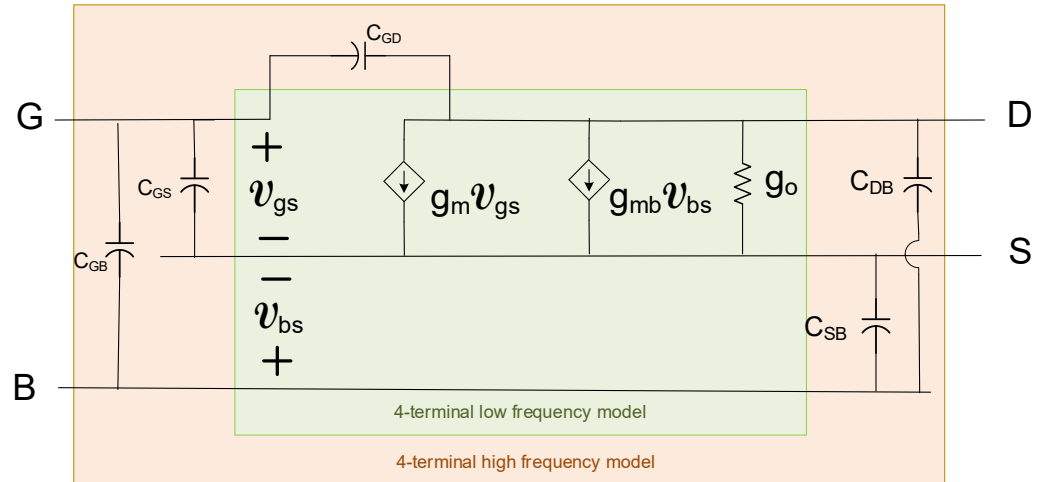
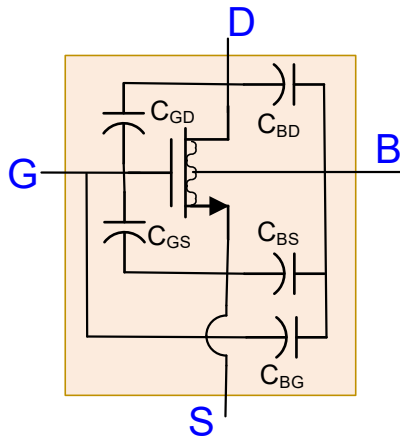
High Frequency Small Signal Model (saturation region)

Often  $V_{BS}=0$  and  $C_{BG}=0$  in saturation, so simplifies to

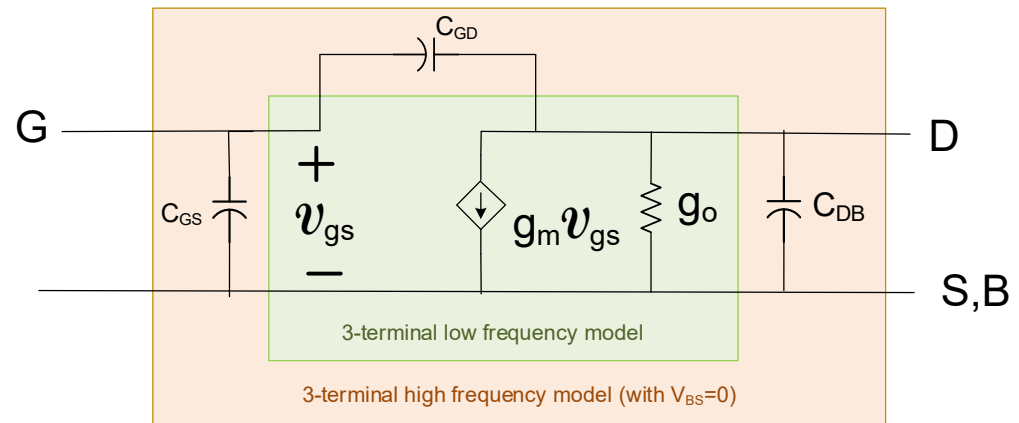
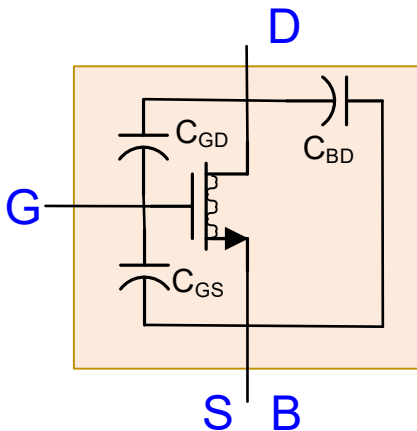


# High Frequency Small-Signal Model

(Saturation Region)

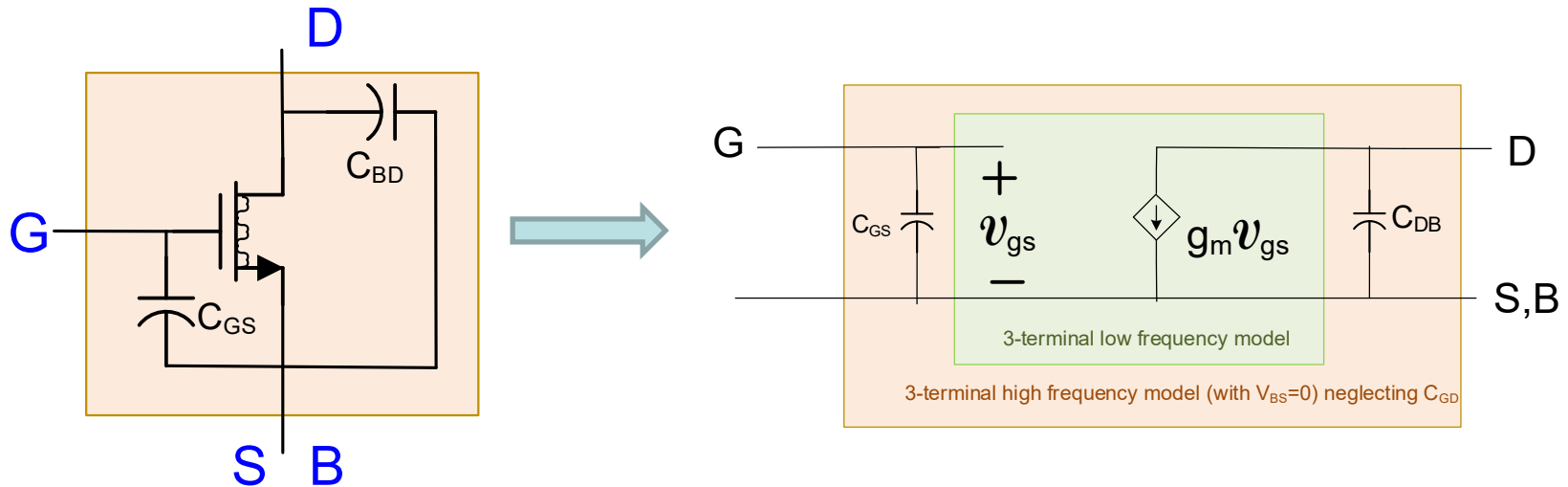


Often  $V_{BS}=0$  and  $C_{BG}=0$ , so simplifies to



# High Frequency Small-Signal Model

Often  $V_{BS}=0$  and  $C_{BG}=0$  and  $C_{GD}$  and  $g_0$  can be neglected so simplifies farther to



Neglecting  $C_{GD}$  which is high frequency feedback from output to input often simplifies analysis considerably

# Recall:

## Small-signal and simplified dc equivalent elements



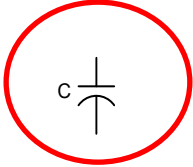














	Element	ss equivalent	Simplified dc equivalent
Capacitors	C Large		
	C Small		
Inductors	L Large		
	L Small		
Diodes			 Simplified
MOS transistors (MOSFET (enhancement or depletion), JFET)			 Simplified
			 Simplified

Have not yet considered situations where the small capacitor is relevant in small-signal analysis



# Recall:

## Small-signal and simplified dc equivalent elements

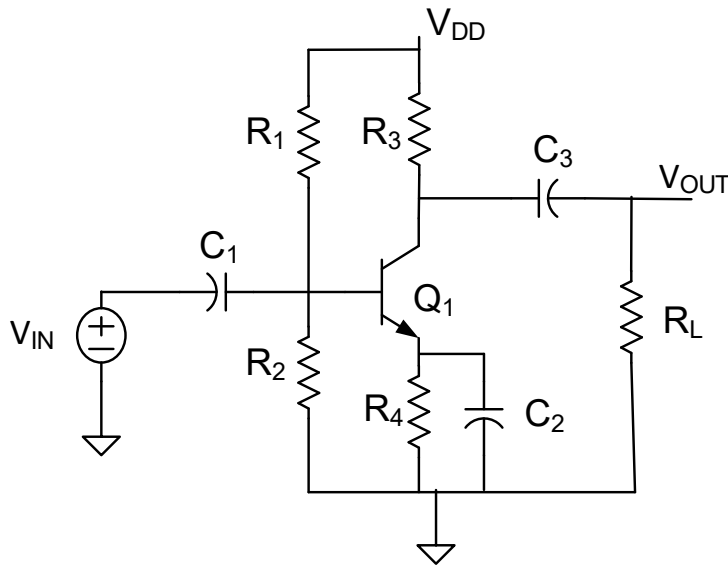
	Element	ss equivalent	Simplified dc equivalent
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Have not yet considered situations where the small capacitor is relevant in small-signal analysis

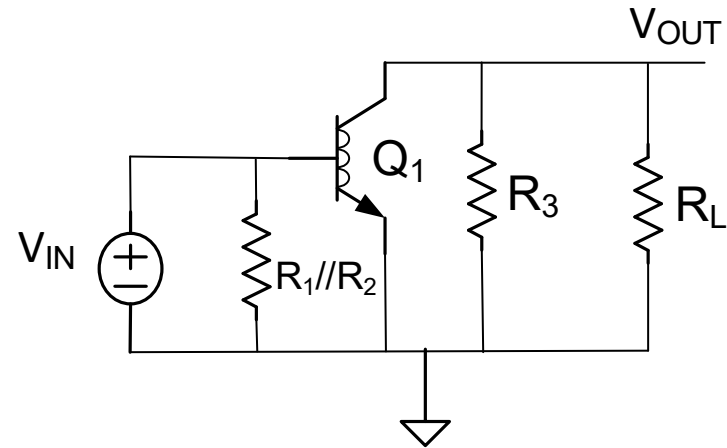
# Amplifiers with Small Capacitors

Consider a bipolar amplifier first where  $C_3$  is a small capacitor but not a parasitic capacitor

Recall:



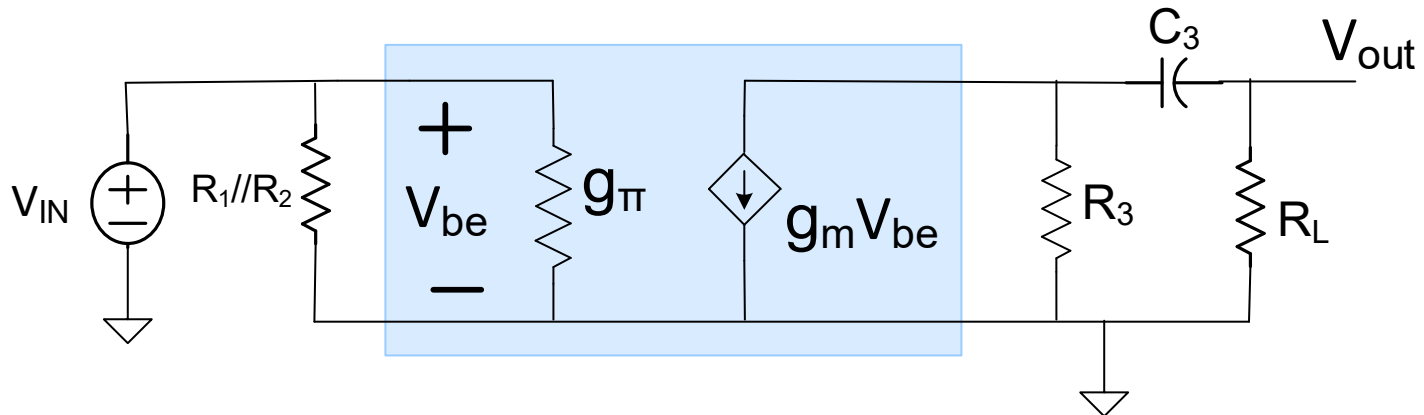
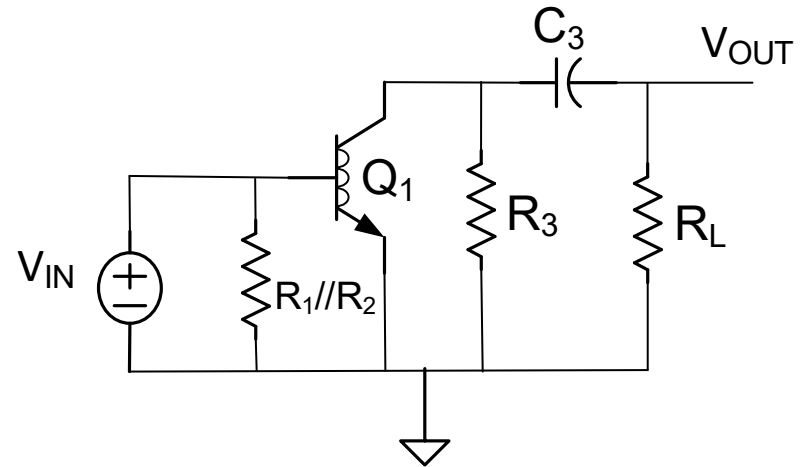
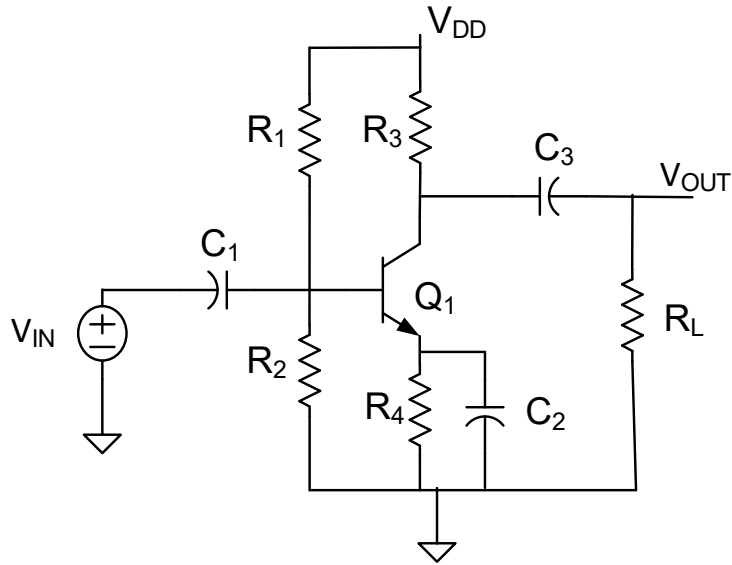
If capacitors are large



$$A_V = -g_{m1} \bullet R_3 // R_L$$

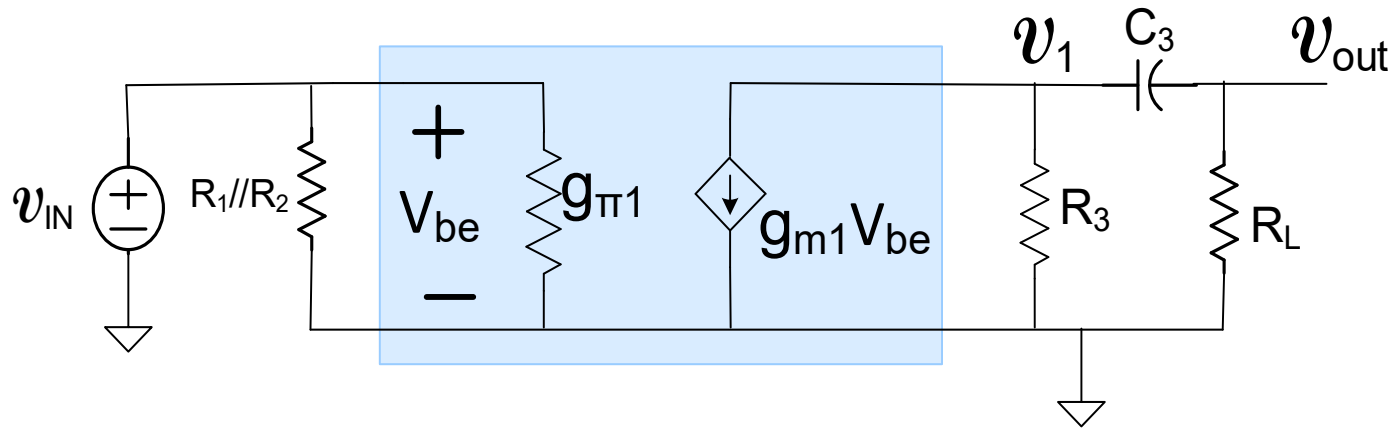
# Amplifiers with Small Capacitors

What if  $C_1$  and  $C_2$  large but  $C_3$  is not large?:



# Amplifiers with Small Capacitors

What if  $C_1$  and  $C_2$  large but  $C_3$  not large?:



From KCL:

$$\left. \begin{aligned} v_{OUT} (sC_3 + G_L) &= v_1 sC_3 \\ v_1 (sC_3 + G_3) + g_{m1} v_{IN} &= v_{OUT} sC_3 \end{aligned} \right\}$$

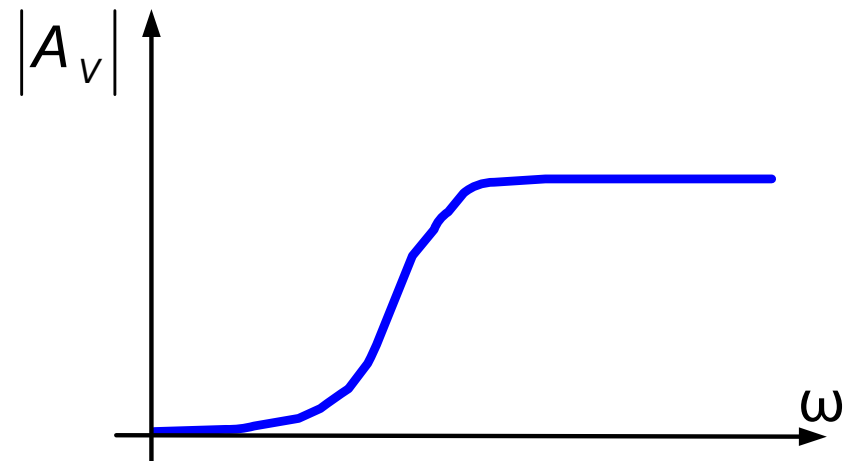
Solving:

$$\frac{v_{OUT}}{v_{IN}} = -\frac{-sC_3 g_{m1}}{sC_3 (G_L + G_3) + G_3 G_L}$$

Equivalently:

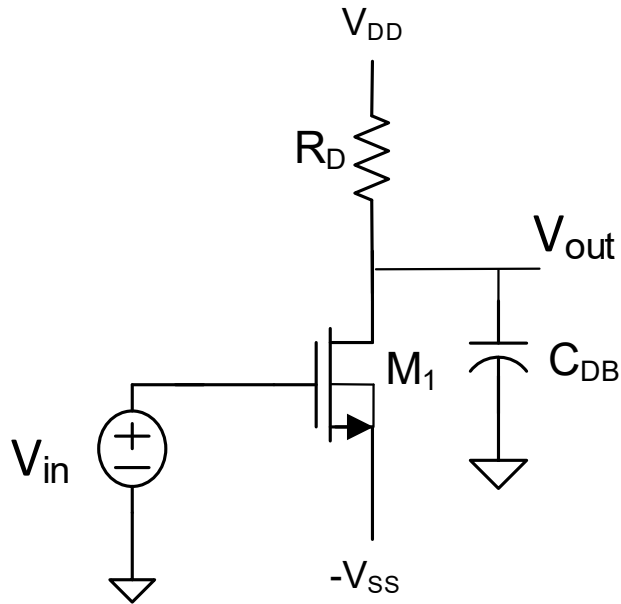
$$\frac{v_{OUT}}{v_{IN}} = -\frac{g_{m1} sC_3 R_3 R_L}{sC_3 (R_L + R_3) + 1}$$

Serves as a first-order high-pass filter

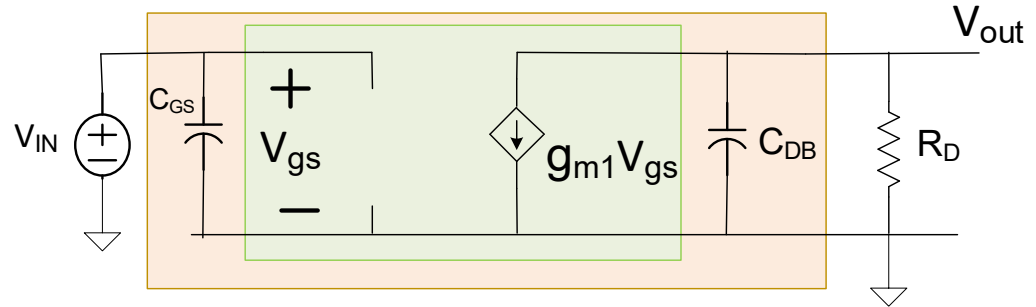


# Amplifiers with Small Capacitors

Consider parasitic  $C_{GS}$  and  $C_{DB}$



(this circuit is different from previous)



By KCL:

$$v_{OUT} (sC_{DB} + G_D) = -g_{m1} v_{IN}$$

Solving:

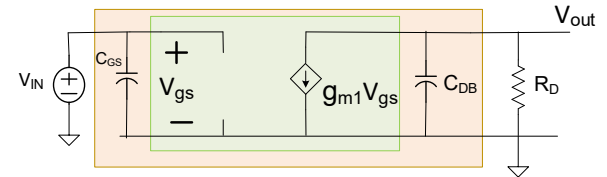
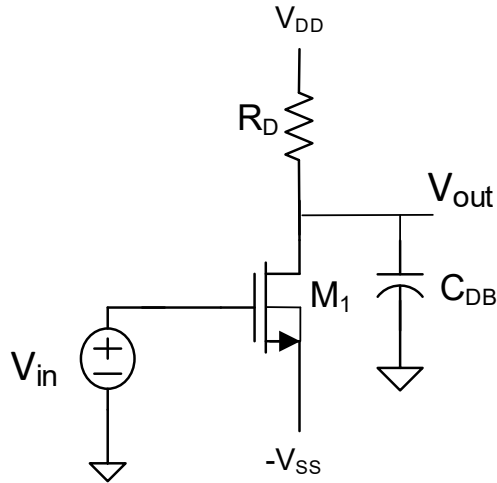
$$\frac{v_{OUT}}{v_{IN}} = -\frac{g_{m1}}{sC_{DB} + G_D}$$

Equivalently:

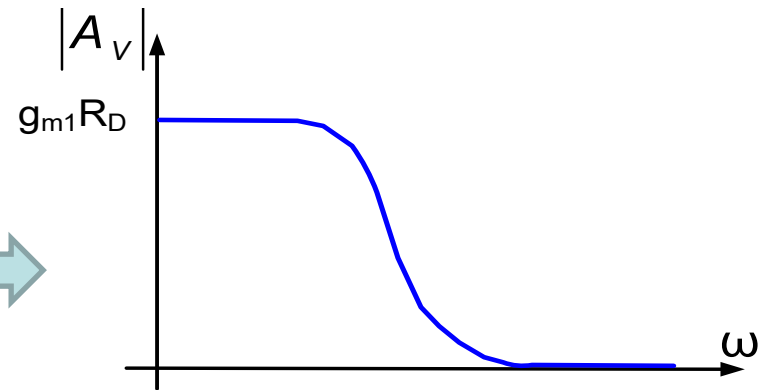
$$\frac{v_{OUT}}{v_{IN}} = \frac{-g_{m1} R_D}{sC_{DB} R_D + 1}$$

# Amplifiers with Small Capacitors

Consider parasitic  $C_{GS}$  and  $C_{DB}$



$$\frac{v_{OUT}}{v_{IN}} = A_V(s) = -\frac{g_{m1}R_D}{sC_{DB}R_D + 1}$$



Since first-order low-pass, half-power frequency given by

$$\omega_{3dB} = \frac{1}{R_D C_{DB}}$$

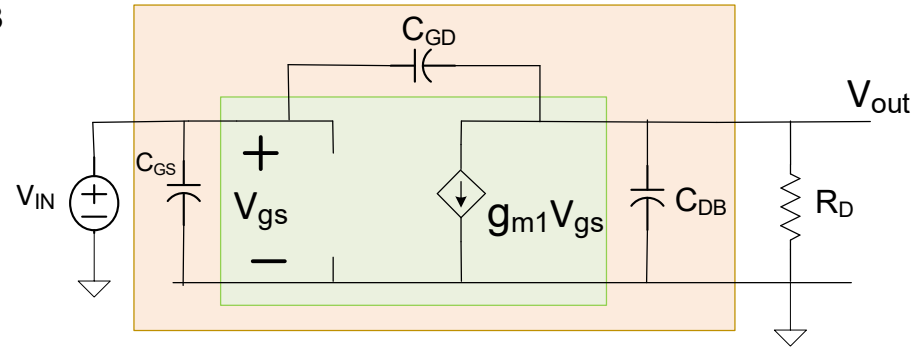
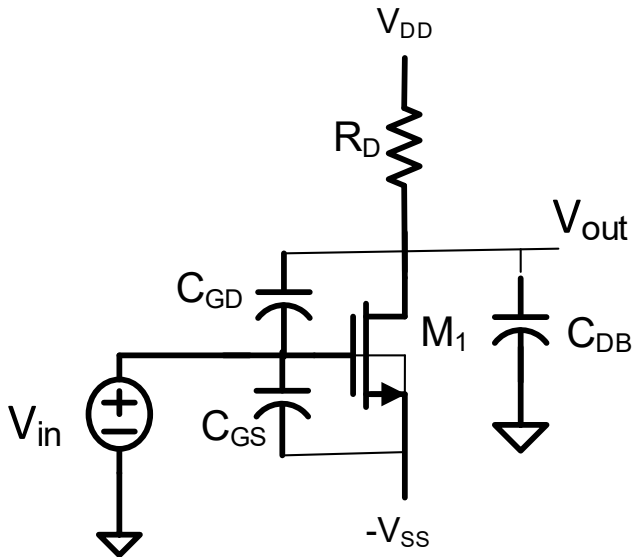
$$A_V(j\omega) = \frac{-g_{m1}R_D}{j\omega C_{DB}R_D + 1}$$

$$|A_V(j\omega)| = \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}}$$

$$\angle A_V(j\omega) = -180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)$$

# Amplifiers with Small Capacitors

Consider parasitic  $C_{GS}$ ,  $C_{GD}$ , and  $C_{DB}$



By KCL:

$$v_{OUT} (s[C_{DB} + C_{GD}] + G_D) = -g_{m1}v_{IN} + sC_{GD}v_{IN}$$

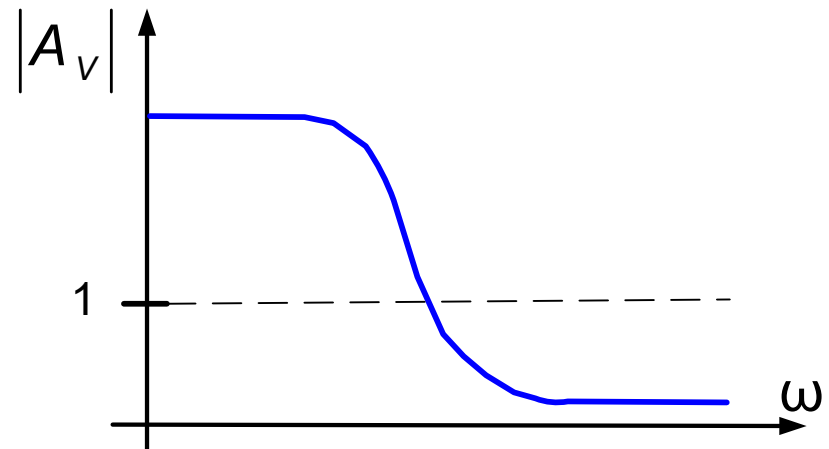
$C_{DB}$  causes gain to decrease at high frequencies  
 $C_{GD}$  causes feed-forward and limits high frequency drop  
 Has one LHP pole and one RHP zero

Solving:

$$\frac{v_{OUT}}{v_{IN}} = -\frac{-g_{m1} + sC_{GD}}{s[C_{DB} + C_{GD}] + G_D}$$

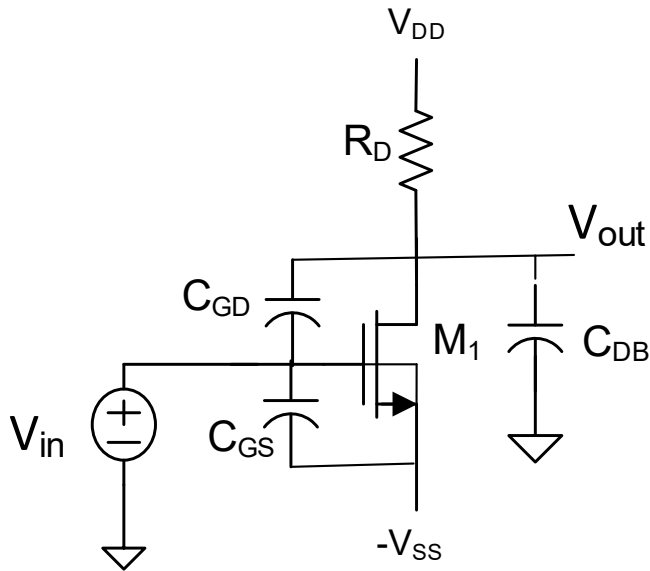
Equivalently:

$$\frac{v_{OUT}}{v_{IN}} = -\frac{-R_D(g_{m1} - sC_{GD})}{s[C_{DB} + C_{GD}]R_D + 1}$$



# Amplifiers with Small Capacitors

Consider parasitic  $C_{GS}$ ,  $C_{GD}$ , and  $C_{DB}$



Device parasitics problematic at high frequencies

$C_{DB}$ ,  $C_{GD}$  and  $C_{GS}$  effects can be significant

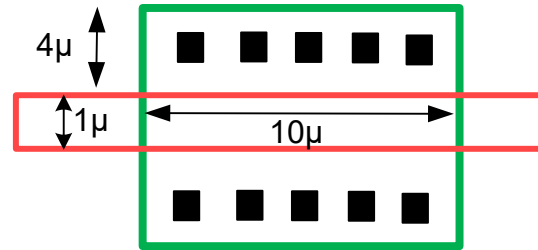
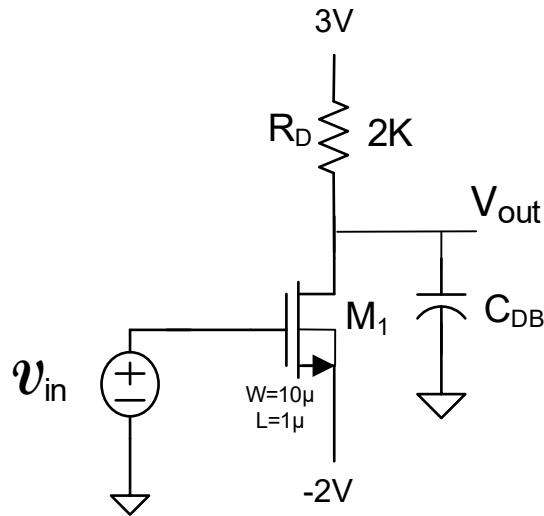
Value of parasitic capacitances strongly dependent upon layout

Device parasitics usually not a problem at audio frequencies

Causes gain to decrease at high frequencies:  
has one high frequency LHP pole and one high frequency RHP zero.



Example: Determine the small-signal voltage gain and the 3dB bandwidth. Consider only the effects of  $C_{DB}$  on the BW. Assume a 0.5u process with  $V_{TH}=0.75V$  and the layout of the transistor shown.



From PDK

$$C_{DB} = C_{BOT} * 40u^2 + C_{SW} * 28u$$

$$C_{BOT} = 942aF/u^2 \quad C_{SW} = 212aF/u$$

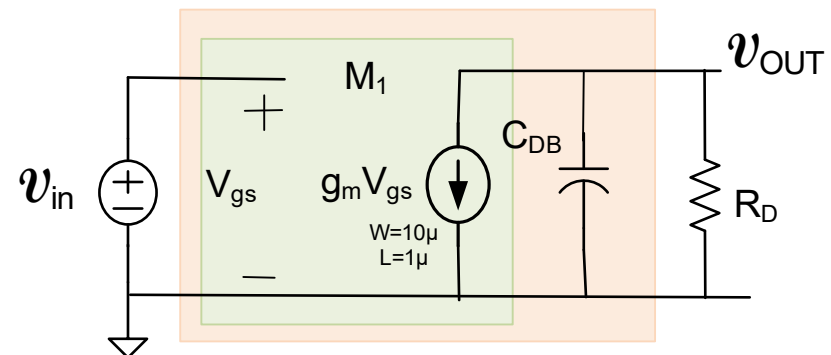
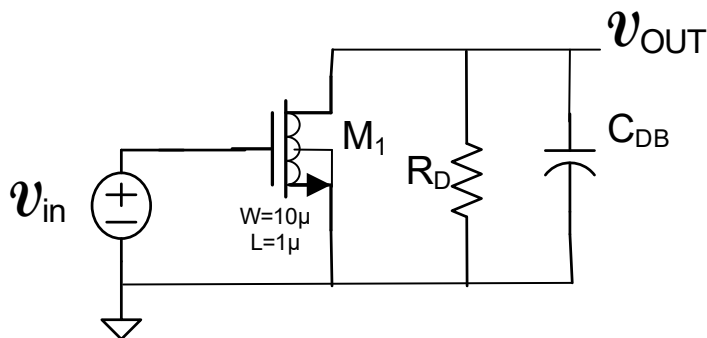
$$C_{DB} = 942aF/u^2 * 40u^2 + 212aF/u * 28u$$

$$C_{DB} = 37.7fF + 5.9fF = 43.6fF$$

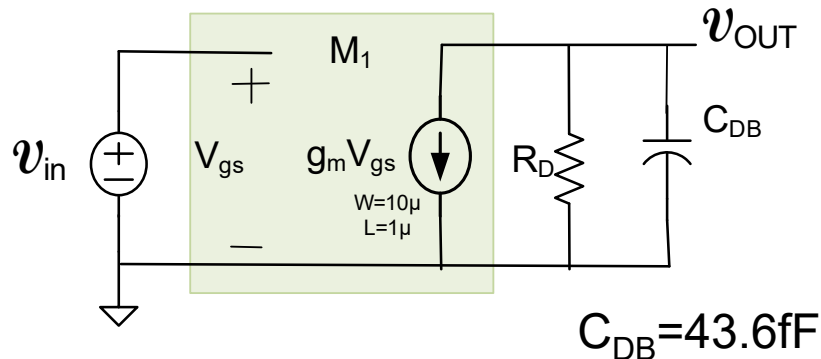
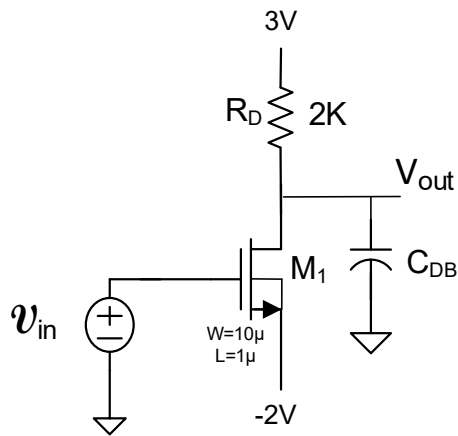
Solution:

$$I_{DQ} = 100\mu A / V^2 \frac{10}{2 \cdot 1} (2 - 0.75)^2 = 0.78mA$$

$$I_{DQ} R_D = 0.78mA \cdot 2K = 1.56$$



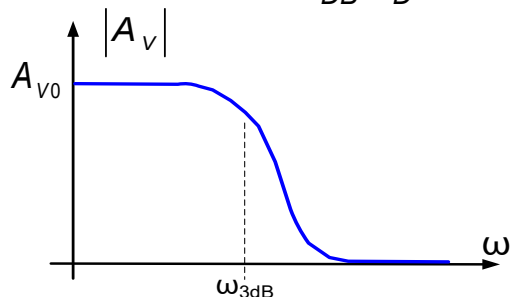
Example: Determine the small-signal dc voltage gain and the 3dB bandwidth. Consider only the effects of  $C_{DB}$  on the BW. Assume a 0.5u process with  $V_{TH}=0.75V$  and the layout of the transistor shown.



Solution continued:

$$v_{OUT} (G_D + sC_{DB}) + g_m v_{IN} = 0$$

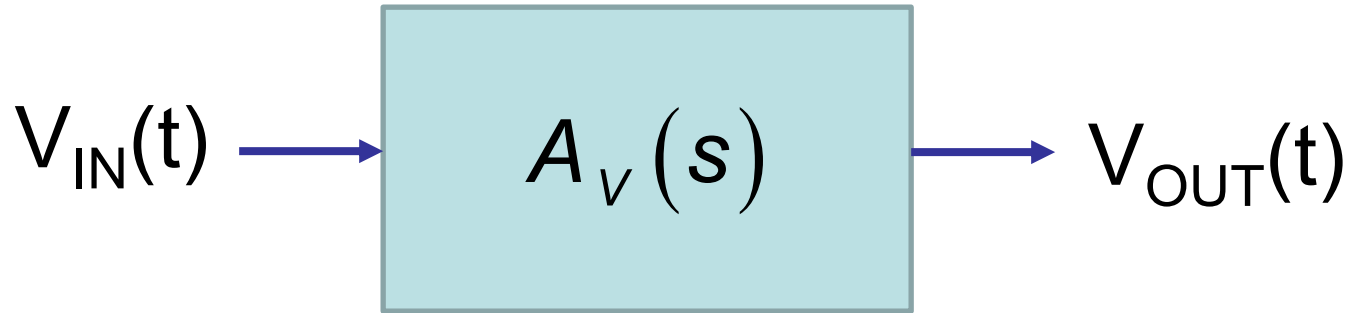
$$v_{OUT} = -v_{IN} \frac{g_m R_D}{1 + sC_{DB} R_D}$$



$$A_{V0} = -g_m R_D = -\frac{2I_{DQ} R_D}{V_{EB}} = -\frac{3.12}{1.25} = -2.5$$

$$f_{3dB} = \frac{1}{2\pi} \cdot \frac{1}{R_D C_{DB}} = 1.8GHz$$

# Sinusoidal Steady State Response for Linear Systems



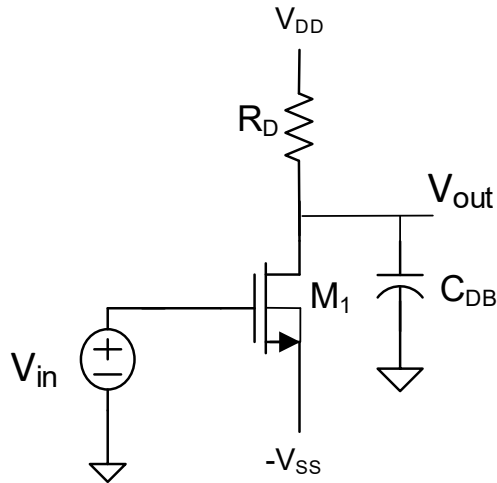
## Key Result from EE 201

If  $V_{IN} = V_m \sin(\omega t + \theta)$  where  $V_m$  is small (so linear operation maintained)

Steady state output is also a sinusoid given by

$$V_{OUT}(t) = V_m |A_V(j\omega)| \sin(\omega t + \theta + \angle A_V(j\omega))$$

# Sinusoidal Steady State Response for Linear Systems



$$|A_V(j\omega)| = \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}}$$

$$\angle A_V(j\omega) = -180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)$$

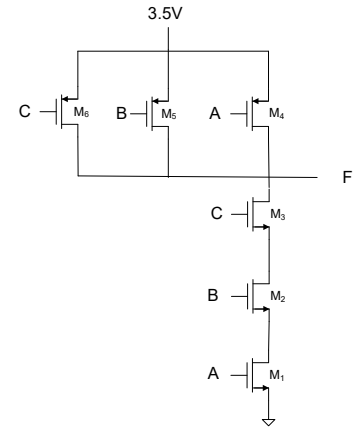
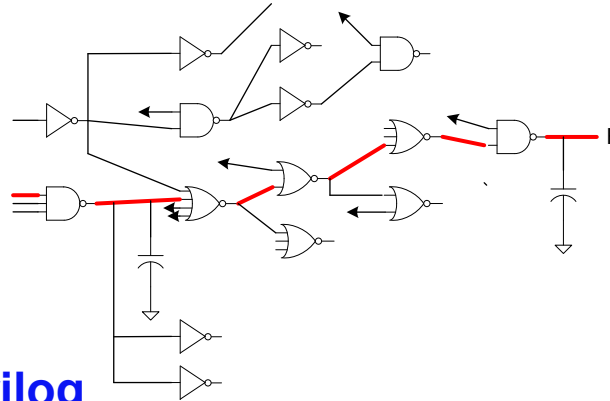
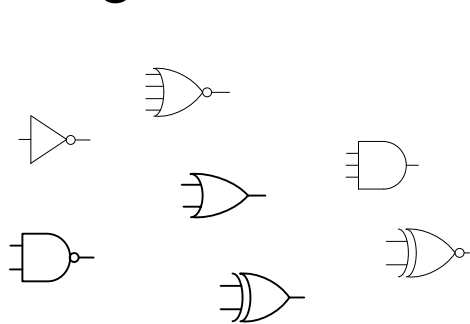
If  $V_{IN} = V_m \sin(\omega t + \theta)$

For  $V_m$  small, small-signal steady state output given by

$$V_{OUT}(t) = V_m \frac{g_{m1}R_D}{\sqrt{(\omega C_{DB}R_D)^2 + 1}} \sin\left(\omega t + \theta - 180^\circ - \tan^{-1}\left(\frac{\omega C_{DB}R_D}{1}\right)\right)$$

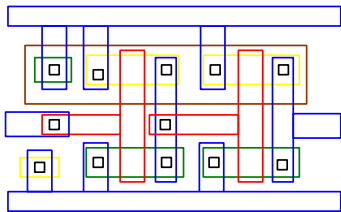
# Digital Circuit Design

Most of the remainder of the course will be devoted to digital circuit design



**Verilog**

**VHDL**



```

module gates (input logic [3:0] a,b,
              output logic [3:0] y1,y2,y3,y4,y5);
  assign y1 = a&b; //AND
  assign y2 = a | b; //OR
  assign y3 = a ^ b; //XOR
  assign y4 = ~(a & b); //NAND
  assign y5 = ~( a | b); //NOR
endmodule
    
```

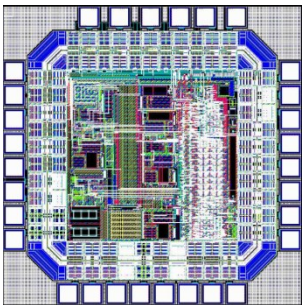
```

library IEEE; use IEEE.STD_LOGIC_1164.all;

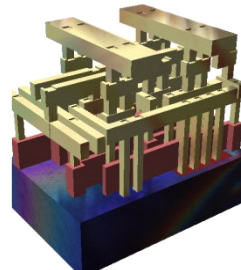
entity gates is
  port(a,b: in STD_LOGIC_VECTOR(3 downto 0);
        y1,y2,y3,y4,y5:out STD_LOGIC_VECTOR(3 downto 0));
end;

architecture synth of gates is
begin

y1 <= a and b;
y2 <= a or b;
y3 <= a xor b;
y4 <= a nand b;
y5 <= a nor b;
end;
    
```

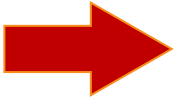


A rendering of a small standard cell with three metal layers (dielectric has been removed). The sand-colored structures are metal interconnect, with the vertical pillars being contacts, typically plugs of tungsten. The reddish structures are polysilicon gates, and the solid at the bottom is the crystalline silicon bulk



Standard Cell Library

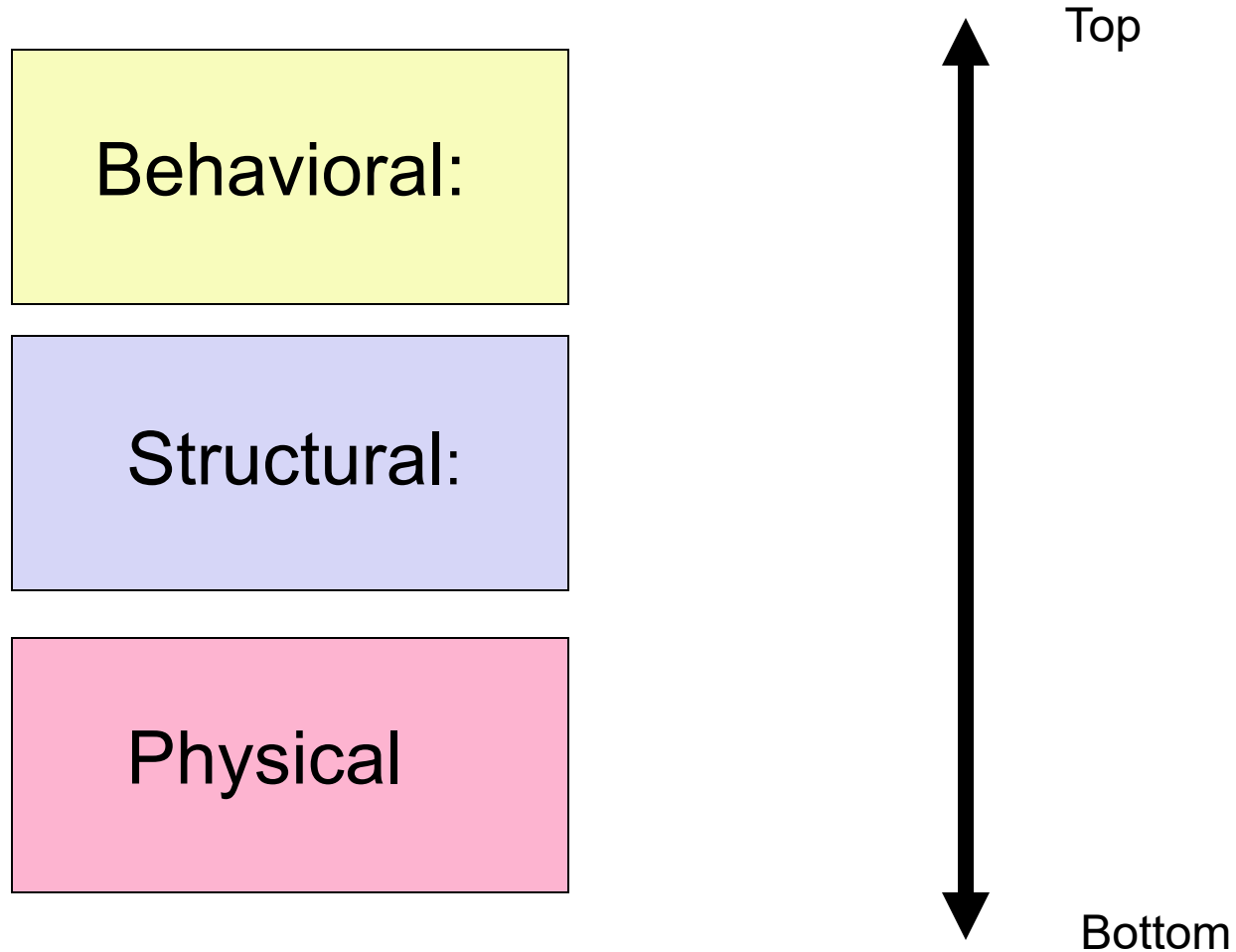
# Digital Circuit Design



## Hierarchical Design

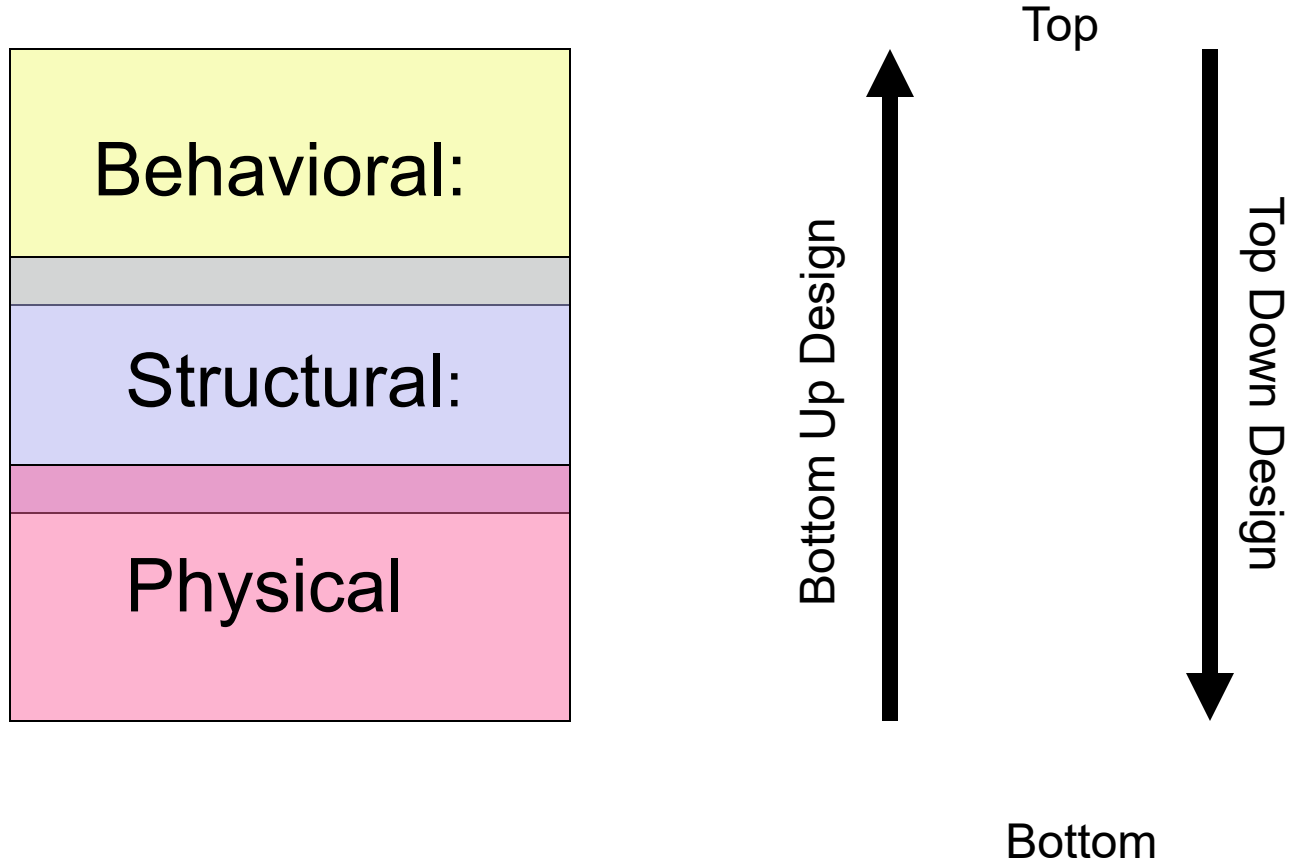
- Basic Logic Gates
  - Properties of Logic Families
  - Characterization of CMOS Inverter
  - Static CMOS Logic Gates
    - Ratio Logic
  - Propagation Delay
    - Simple analytical models
      - FI/OD
      - Logical Effort
    - Elmore Delay
  - Sizing of Gates
    - The Reference Inverter
- 
- Propagation Delay with Multiple Levels of Logic
  - Optimal driving of Large Capacitive Loads
  - Power Dissipation in Logic Circuits
  - Other Logic Styles
  - Array Logic
  - Ring Oscillators

# Hierarchical Digital Design Domains:



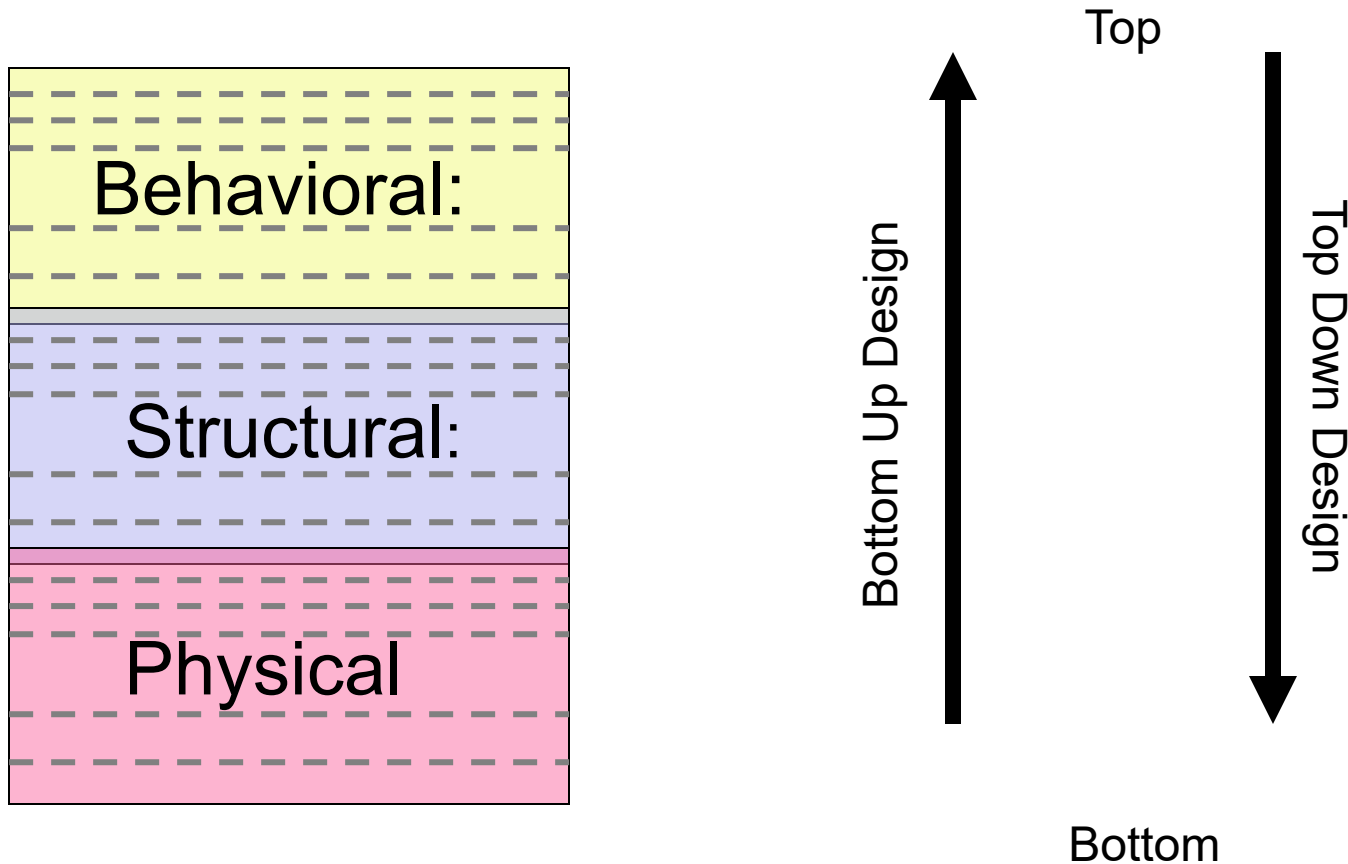
Multiple Levels of Abstraction

# Hierarchical Digital Design Domains:





# Hierarchical Digital Design Domains:



Multiple Sublevels in Each Major Level

All Design Steps may not Fit Naturally in this Description

# Hierarchical Digital Design Domains:

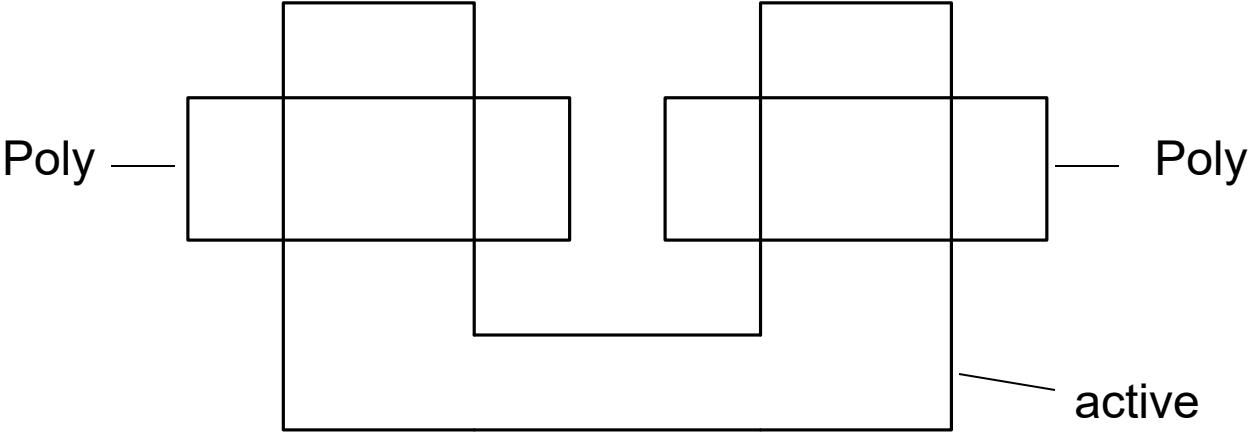
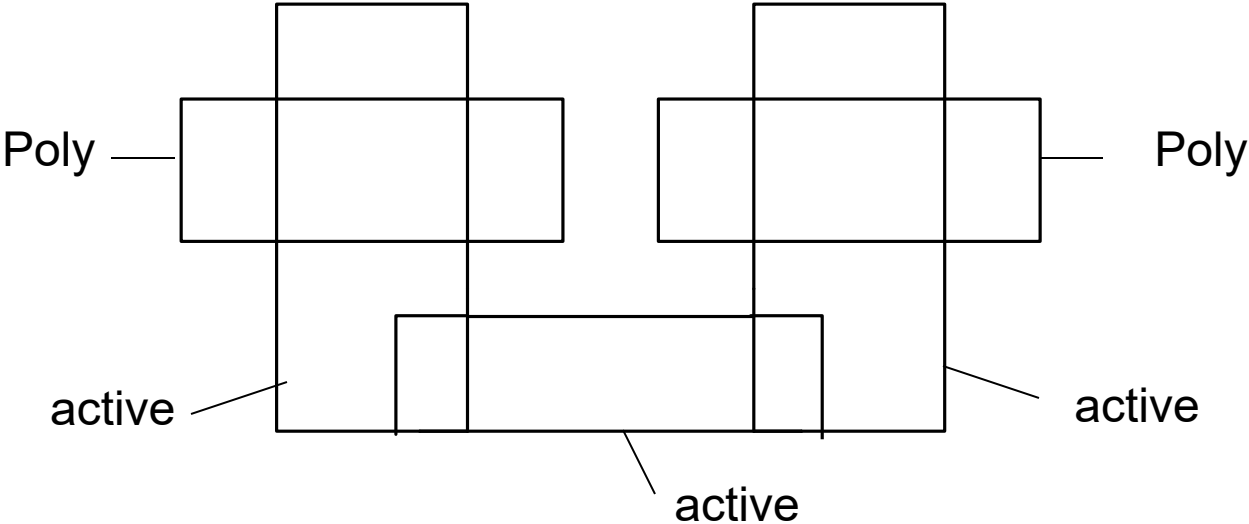
**Behavioral** : Describes what a system does or what it should do

**Structural** : Identifies constituent blocks and describes how these blocks are interconnected and how they interact

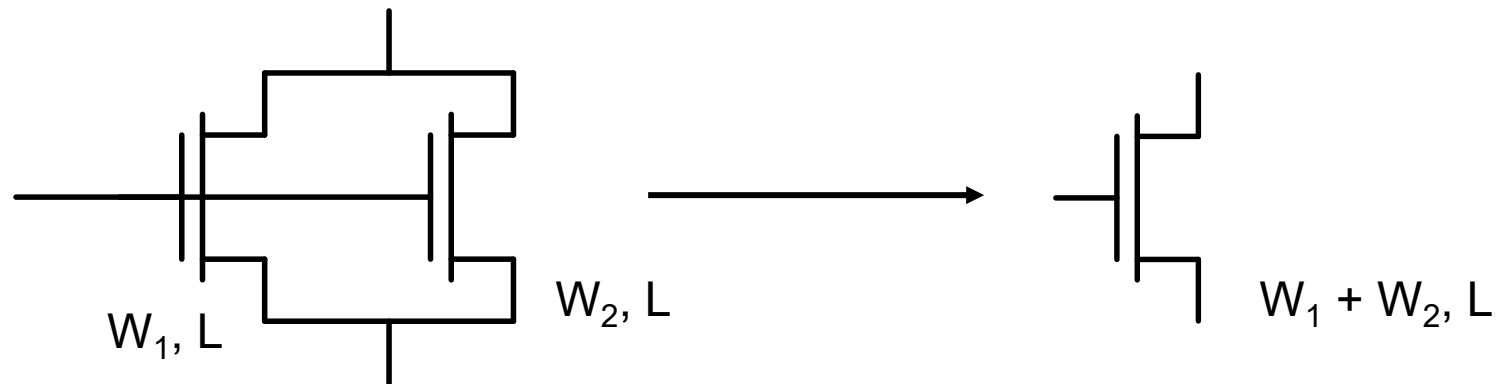
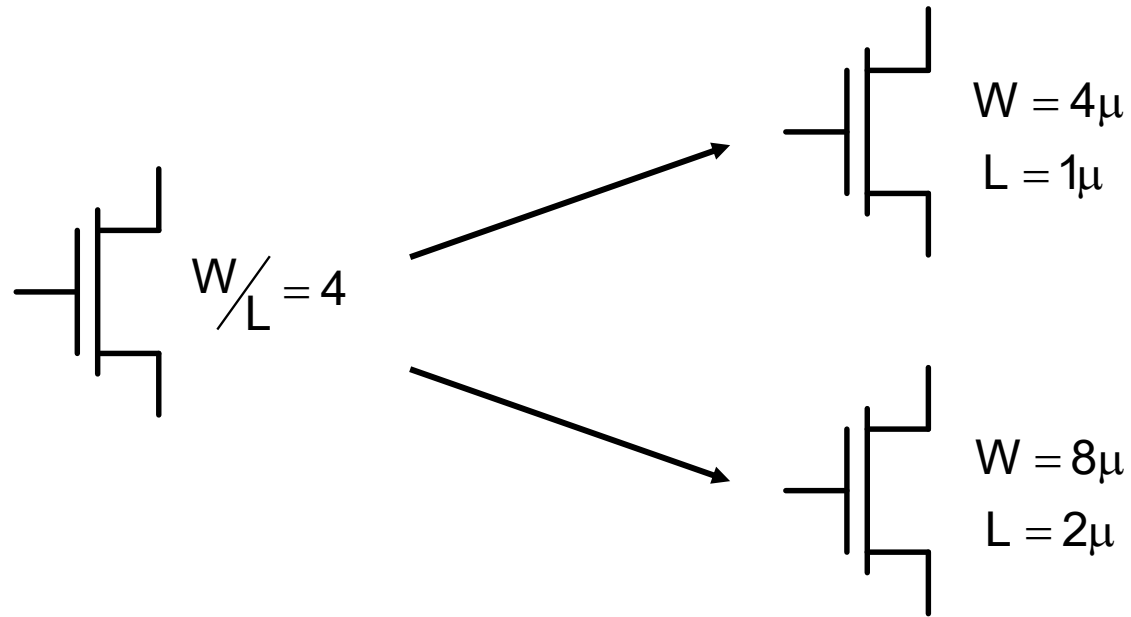
**Physical** : Describes the constituent blocks to both the transistor and polygon level and their physical placement and interconnection

Multiple representations often exist at any level or sublevel

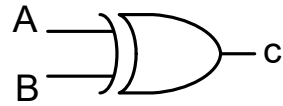
Example: Two distinct representations at the physical level (polygon sublevel)



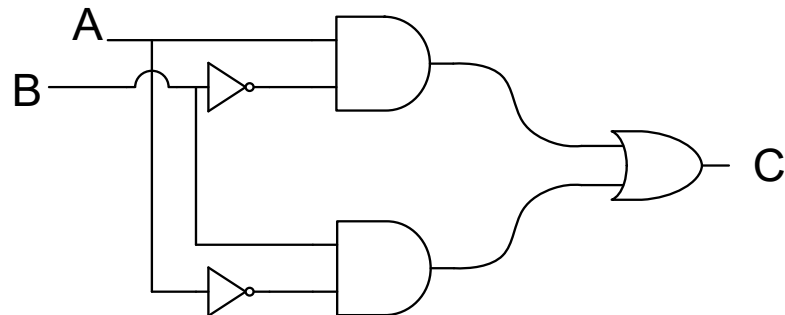
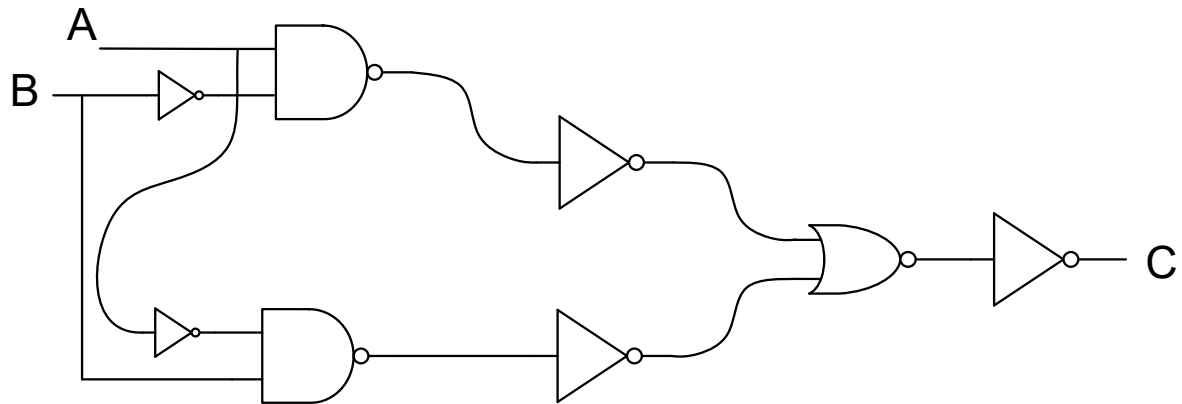
# Example: Two distinct representations at physical level (schematic sublevel)



Example: Three distinct representations at the structural/behavioral level (gate sublevel)



$$C = A \oplus B$$



In each domain, multiple levels of abstraction are generally used.

### Consider Physical Domain

- Consider lowest level to highest
  - 0 - placement of diffusions, thin oxide regions, field oxide, ect. on a substrate.
  - 1 - polygons identify all mask information  
(not unique)
  - 2 - transistors  
(not unique)
  - 3 - gate level  
(not unique)
  - 4 - cell level  
Adders, Flip Flop, MUTs,...

### Information Type

**PG data**

**G.D.F**

**Netlist**

**HDL Description**

## Structural Domain:

- DSP
- Blocks (Adders, Memory, Registers, etc.)
- Gates
- Transistor

## Information Type

HDL

Netlists

## Behavior Domain (top down):

- Application
- Programs
- Subroutines
- Boolean Expressions

## Information Type

High-Level Language  
HDL



# Representation of Digital Systems

## Standard Approach to Digital Circuit Design

### 8 – level representation

1. Behavioral Description
  - Technology independent
2. RTL Description (Register Transfer Level)  
(must verify (1)  $\Leftrightarrow$  (2))
3. RTL Compiler
  - Registers and Combinational Logic Functions
4. Logic Optimizer
5. Logic Synthesis
  - Generally use a standard cell library for synthesis

(sublevels 6-8 not shown on this slide)

# Frontend design

## Representation of Digital Systems

### Standard Approach to Digital Circuit Design

1. Behavioral Description
  - Technology independent
2. RTL Description
  - (must verify (1)  $\Leftrightarrow$  (2))
3. RTL Compiler
  - Registers and Combinational Logic Functions
4. Logic Optimizer

## 5. Logic Synthesis

Generally use a standard cell library for synthesis



# Backend design

## 6. Place and Route

(physically locates all gates and registers and interconnects them)

### 7. Layout Extraction

- DRC
- Back Annotation

### 8. Post Layout simulation

May necessitate a return to a higher level in the design flow

Logic synthesis, though extensively used, often is not as efficient nor as optimal for implementing some important blocks or some important functions

These applications generally involve transistor level logic circuit design that may combine one or more different logic design styles

**End of Lecture 36**